



DKZ/58/2011

Warsaw, 17.06.2011.

**Re: The open procedure for delivery of the two Reflux baths for wet etching in KOH.**

With regard to the following questions:

1. *Ref. the solution temperature range 0-180 C. Does it mean that the KOH solution must be cooled down to 0 C or heated up to 180 C?*
2. *Is it possible to made the tanks with a SS covered with PTFE?*
3. *Is it allowed to deliver a modular system?*
4. *Can the system components be made by different manufacturers if the system is modular?*
5. *What is the max concentration of the KOH solution?*

we kindly inform that:

**Ad. 1**

The ambient temperature is predicted as the lowest temperature of the solution; the tool must have the ability to use at the elevated temperatures specified in the requirements.

**Ad. 2**

No.

**Ad. 3**

Yes.

**Ad. 4**

The components of the system might be made by different manufacturers; the whole system, however, must be tested and the provider of the system must ensure that all the components are fully compatible with each other.

**Ad. 5**

Ca. 50 wt %.

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